

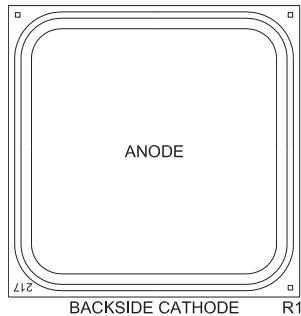
The CPC01 Silicon Carbide Schottky die is optimized for high temperature applications. Parametrically, the device is energy efficient as a result of low total conduction losses and minimal changes to switching characteristics as a function of temperature.

FEATURES:

- Positive temperature coefficient
- Low reverse leakage current
- Temperature independent switching characteristics
- High operating junction temperature
- Metalization suitable for standard die attach technologies
- Top metalization optimized for wire bonding

APPLICATIONS:

- Power inverters
- Industrial motor drives
- Switch-mode power supplies
- Power factor correction
- Over-current protection



MECHANICAL SPECIFICATIONS:

Die Size	98 x 98 MILS
Die Thickness	13.8 MILS \pm 0.8 MILS
Die Passivation	SiN / SiO ₂ / PI
Anode Bonding Pad Area	75 x 75 MILS
Top Side Metalization	Al – 40,000Å
Back Side Metalization	Ti/W/Au – 200Å/1,000Å/1,000Å
Wafer Diameter	4 INCHES
Gross Die Per Wafer	1,100

MAXIMUM RATINGS: ($T_A=25^\circ\text{C}$)

	SYMBOL		UNITS
Peak Repetitive Reverse Voltage	V_{RRM}	1200	V
DC Blocking Voltage	V_R	1200	V
Continuous Forward Current	I_F	10	A
Peak Forward Surge Current ($t_p=8.3\text{ms}$)	I_{FSM}	50	A
Operating and Storage Junction Temperature	T_J, T_{stg}	-55 to +225	°C

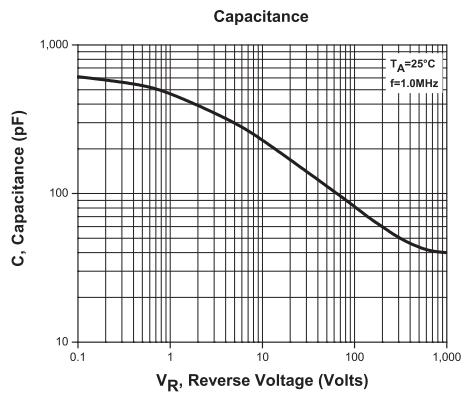
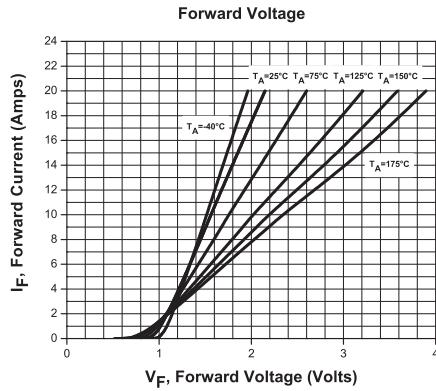
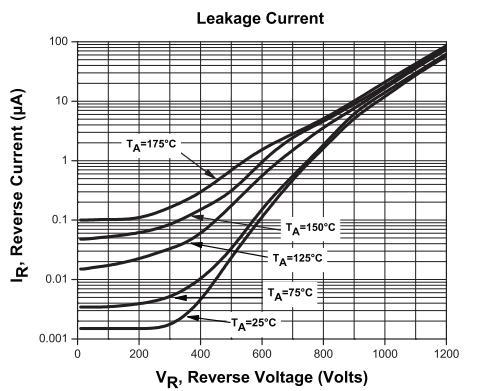
ELECTRICAL CHARACTERISTICS: ($T_A=25^\circ\text{C}$ unless otherwise noted)

SYMBOL	TEST CONDITIONS	TYP	MAX	UNITS
I_R	$V_R=1200\text{V}$	60	400	µA
I_R	$V_R=1200\text{V}, T_J=175^\circ\text{C}$	0.09	1.0	mA
V_F	$I_F=10\text{A}$	1.55	1.8	V
V_F	$I_F=10\text{A}, T_J=175^\circ\text{C}$	2.3	3.0	V
Q_C	$V_R=800\text{V}, I_F=10\text{A}, di/dt=750\text{A}/\mu\text{s}$	54		nC
C_J	$V_R=1.0\text{V}, f=1.0\text{MHz}$	477		pF
C_J	$V_R=300\text{V}, f=1.0\text{MHz}$	50		pF
C_J	$V_R=600\text{V}, f=1.0\text{MHz}$	41		pF

R0 (20-March 2013)

CPC01

Typical Electrical Characteristics



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